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APPLICATION NUMBER	FILING or 371(c) DATE	GRP ART UNIT	FIL FEE REC'D	ATTY DOCKET NO	DRAWINGS	TOT CLAIMS	IND CLAIMS
10/554,397	09/26/2006	1745	1430	279648US0PCT	3	18	5

CONFIRMATION NO. 2754

## FILING RECEIPT

22850  
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1940 DUKE STREET  
ALEXANDRIA, VA22314

Date Mailed: 12/04/2006

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## Applicant(s)

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Power of Attorney: The patent practitioners associated with Customer Number 22850

## Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/05527 04/16/2004

## Foreign Applications

JAPAN 2003-123938 04/28/2003  
JAPAN 2003-295363 08/19/2003  
JAPAN 2003-297443 08/21/2003  
JAPAN 2003-299701 08/25/2003

If Required, Foreign Filing License Granted: 12/01/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is  
**US10/554,397**

Projected Publication Date: 03/15/2007

Non-Publication Request: No

Early Publication Request: No

**Title**

Negative electrode for lithium secondary cell, lithium secondary cell employing the negative electrode, film deposition material b used for forming negative electrode, and process for producing negative electrode

**Preliminary Class**

429

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